

# **Superconductive Positron Stacking Ring**

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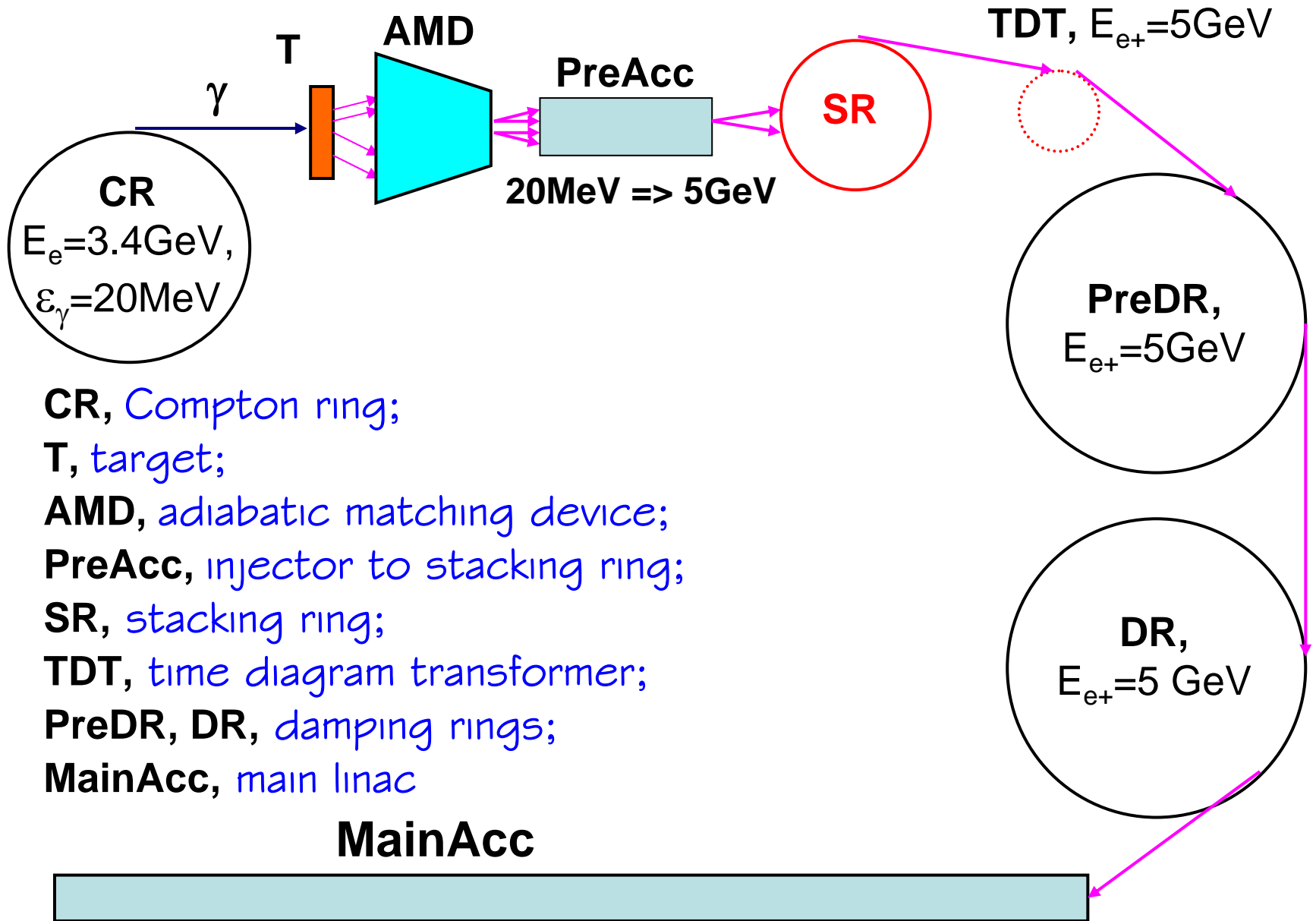
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## Conclusions:

For continuous positron injection  
we need SR with damping time of 100  $\mu$ s

## Possible ways:

Injection in longitudinal plane;  
Fast damping under extremely intensive CS;  
Superconductive fields



**CR**, Compton ring;

**T**, target;

**AMD**, adiabatic matching device;

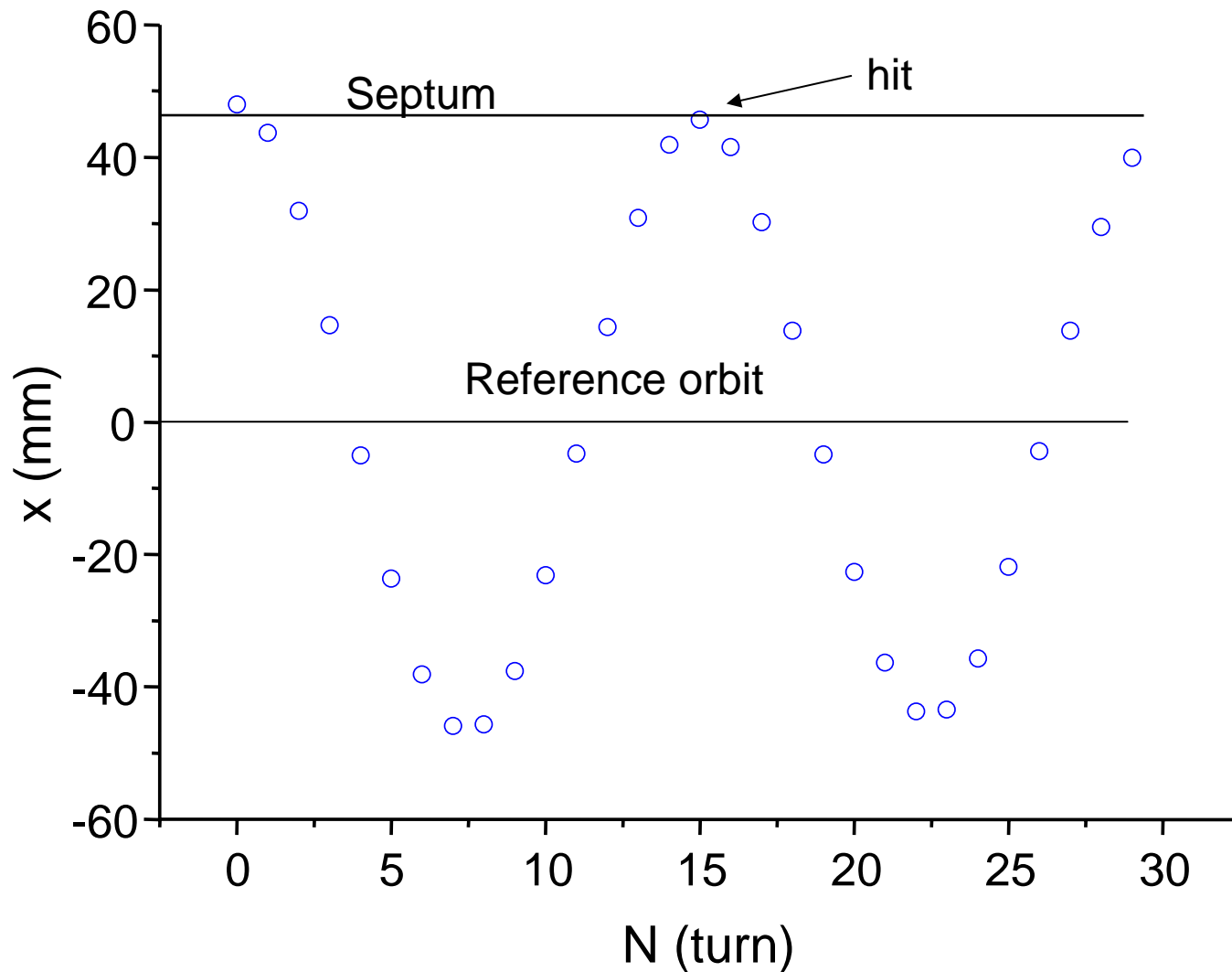
**PreAcc**, injector to stacking ring;

**SR**, stacking ring;

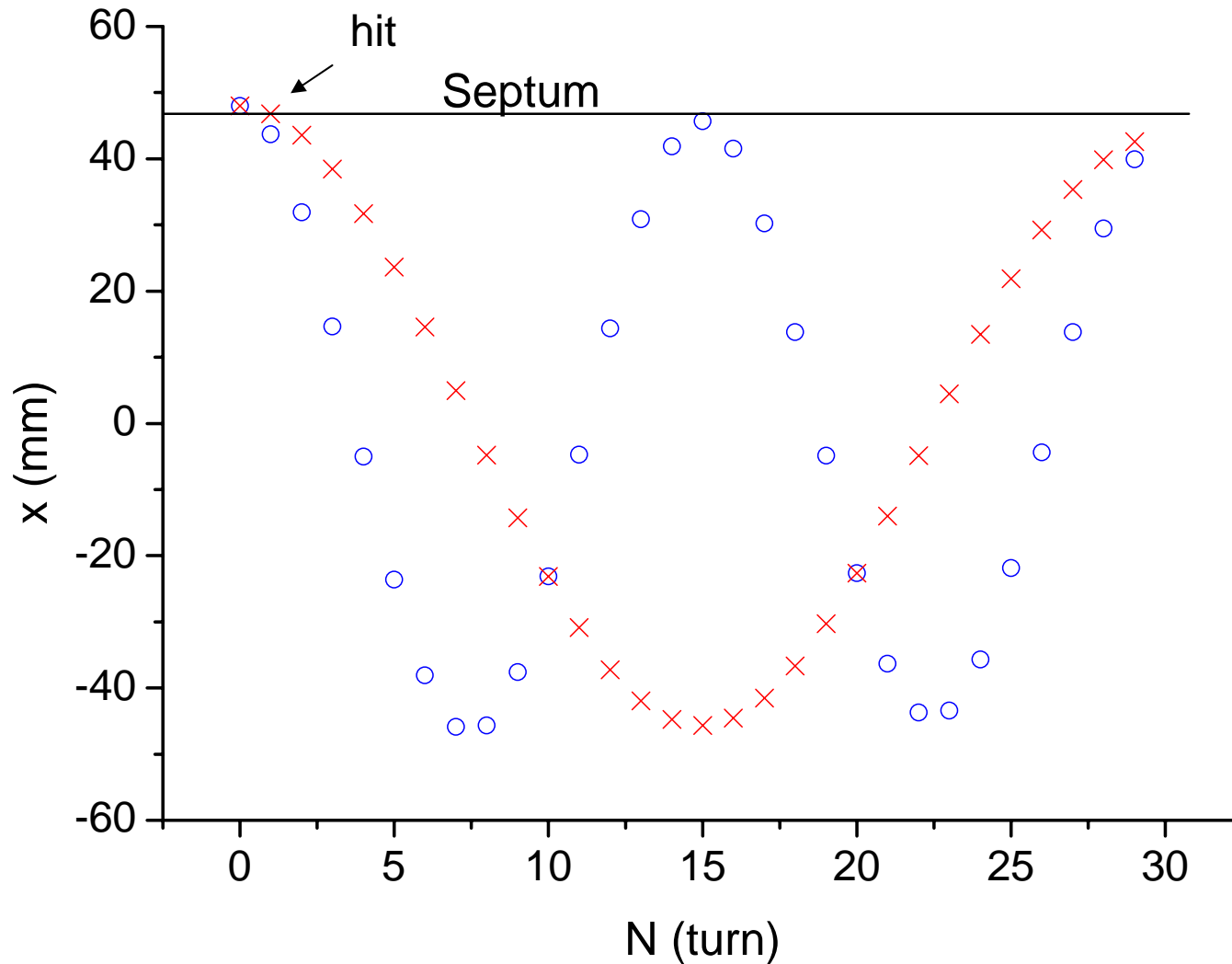
**TDT**, time diagram transformer;

**PreDR, DR**, damping rings;

**MainAcc**, main linac



Positions of equilibrium orbit. Dispersion at injection azimuth  $\eta=0.6$  m,  
 momentum deviation  $\Delta p/p=8$  %, synchrotron frequency  $Q_s = 1/15$ .  
 Ring circumference  $C=100$  m, synchrotron damping  $\tau_s=100$   $\mu$ s (333 turns)



Positions of equilibrium orbit. Dispersion at injection azimuth  $\eta=0.6$  m, momentum deviation  $\Delta p/p=8$  %, synchrotron frequency  $Q_s = 1/15; 1/30$ . Ring circumference  $C=100$  m, synchrotron damping  $\tau_s=100 \mu\text{s}$  (333 turns)

## Synchrotron damping time

$$\tau_s [\text{turn}] \approx E_0 / \Delta E$$

## Energy losses

$$\Delta E [\text{MeV}] = 0.0885 E^4 [\text{GeV}] / \rho [\text{m}]$$

$$E_0 [\text{GeV}] = 0.3 B [\text{T}] \rho [\text{m}]$$

$$B = 10 \text{ T} \Rightarrow E_0 [\text{GeV}] = 3 \rho [\text{m}], \rho [\text{m}] = E_0 [\text{GeV}] / 3$$

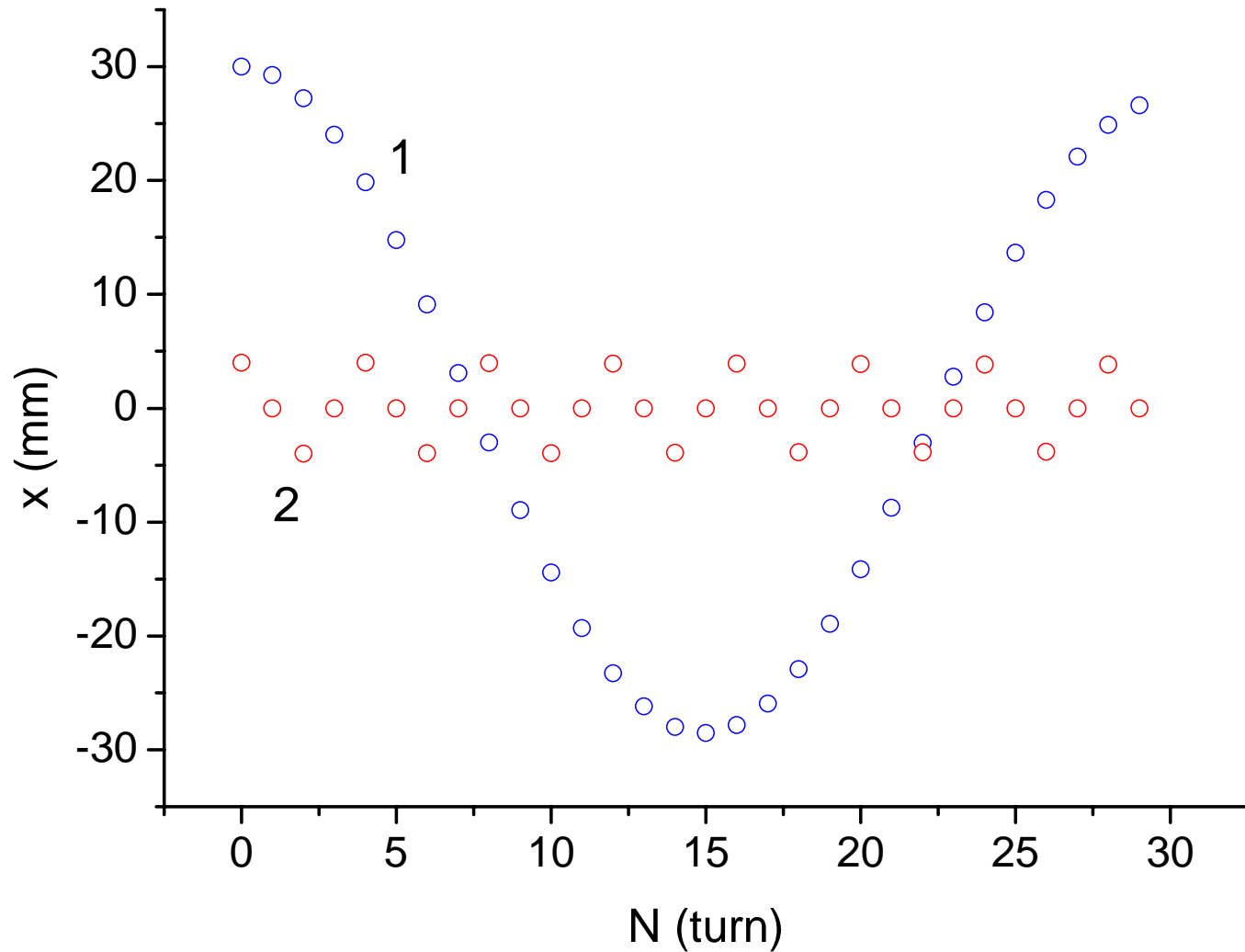
$$\Delta E [\text{MeV}] = 0.265 E_0^3 [\text{GeV}]$$

## Damping times

$$E_0 = 1 \text{ GeV}, \Delta E = 0.265 \text{ MeV} \Rightarrow 3750 \text{ turns } (\tau_s = 1250 \mu\text{s})$$

$$E_0 = 2 \text{ GeV}, \Delta E = 2.125 \text{ MeV} \Rightarrow 940 \text{ turns } (\tau_s = 315 \mu\text{s})$$

$$E_0 = 3 \text{ GeV}, \Delta E = 7.170 \text{ MeV} \Rightarrow 420 \text{ turns } (\tau_s = 140 \mu\text{s})$$

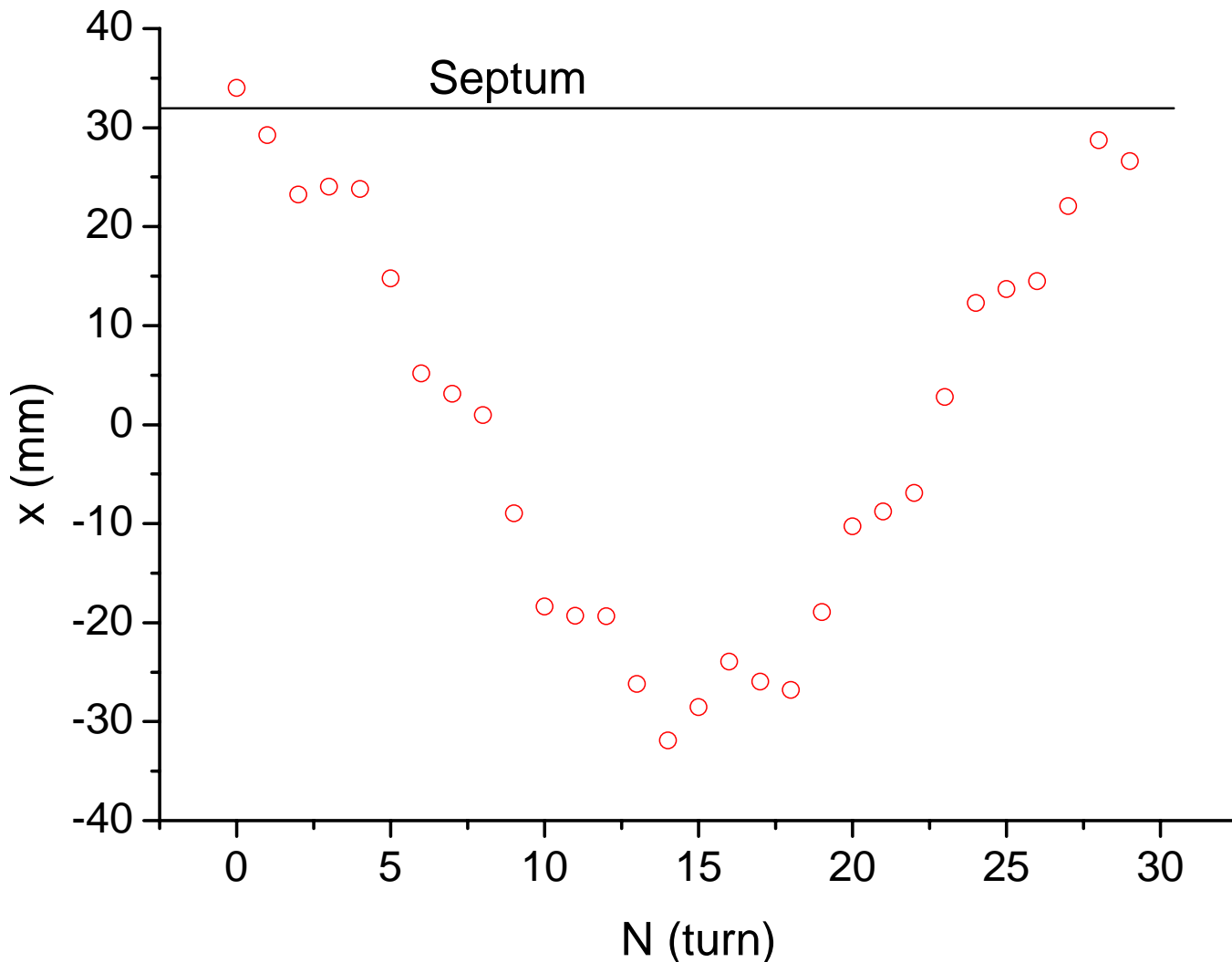


Positions of equilibrium orbit (1) and betatron oscillations (2).

Dispersion at injection azimuth  $\eta = 1.0$  m,

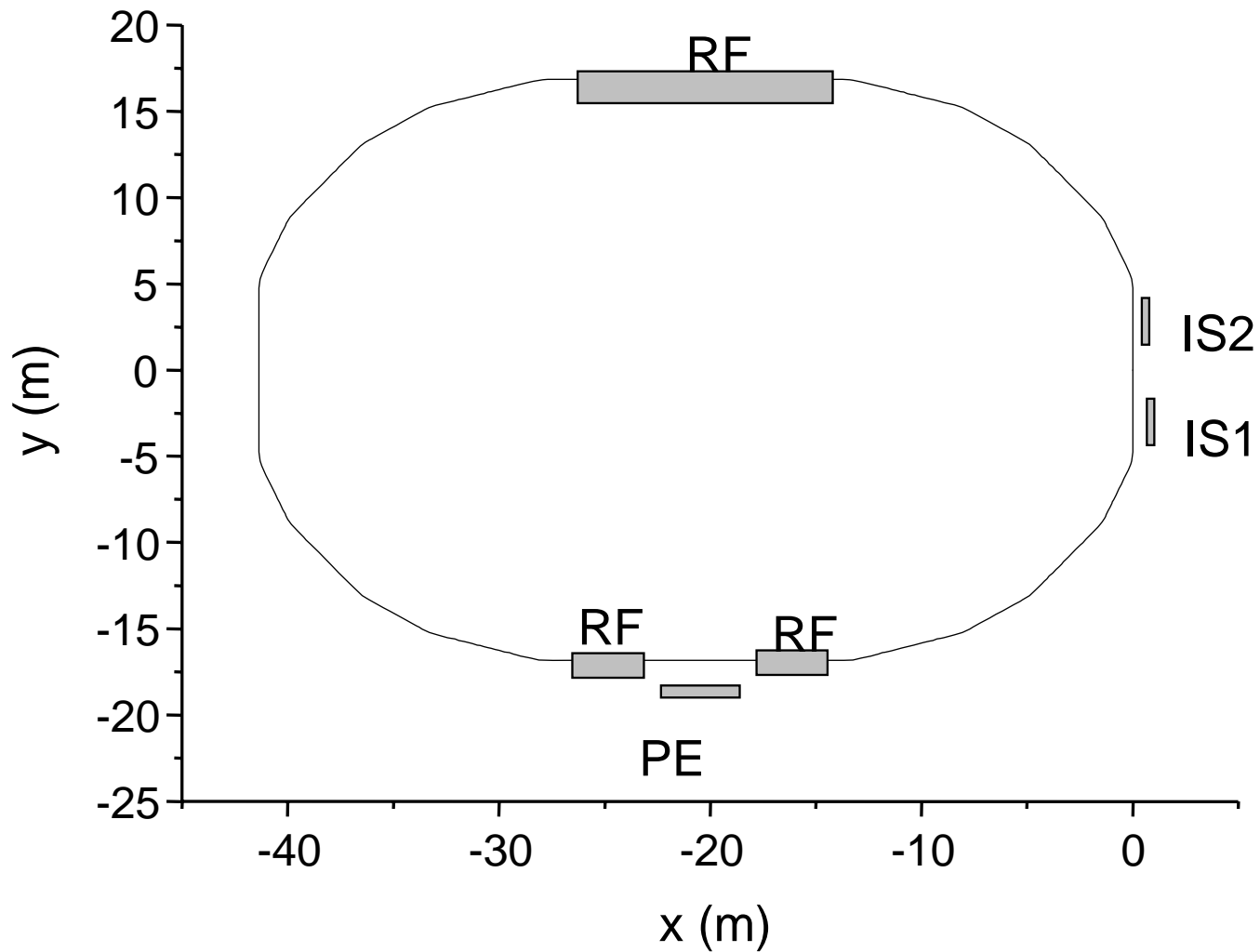
momentum deviation  $\Delta p/p = 3\%$ , synchrotron frequency  $Q_s = 1/30$ .

Ring circumference  $C = 100$  m, synchrotron damping  $\tau_s = 100 \mu\text{s}$  (333 turns)

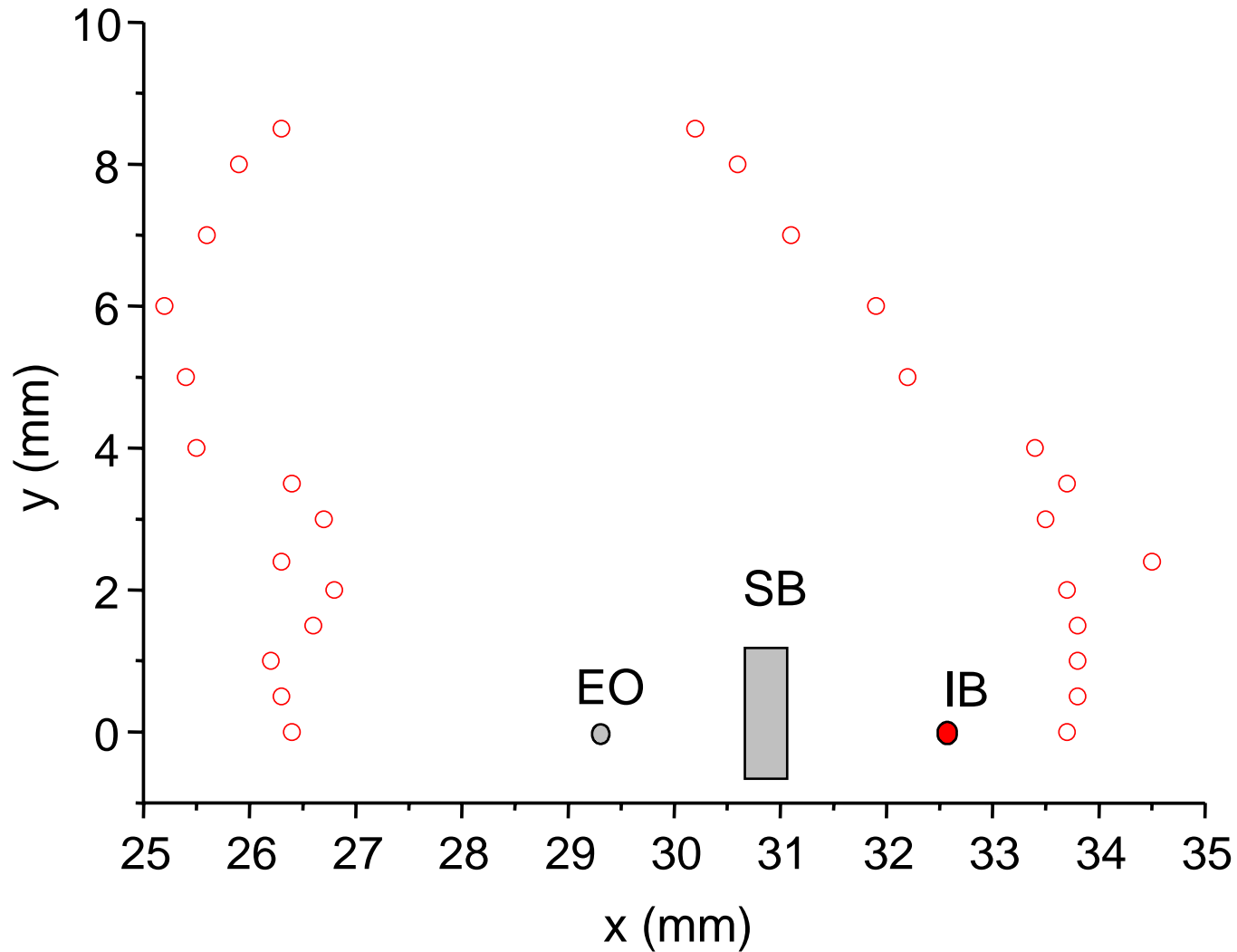


Positions of injected particle. Dispersion at injection azimuth  $\eta = 1.0$  m,  
betatron amplitude  $X_b = 5$  mm, momentum deviation  $\Delta p/p = 3$  %,  
synchrotron frequency  $Q_s = 1/30$ .

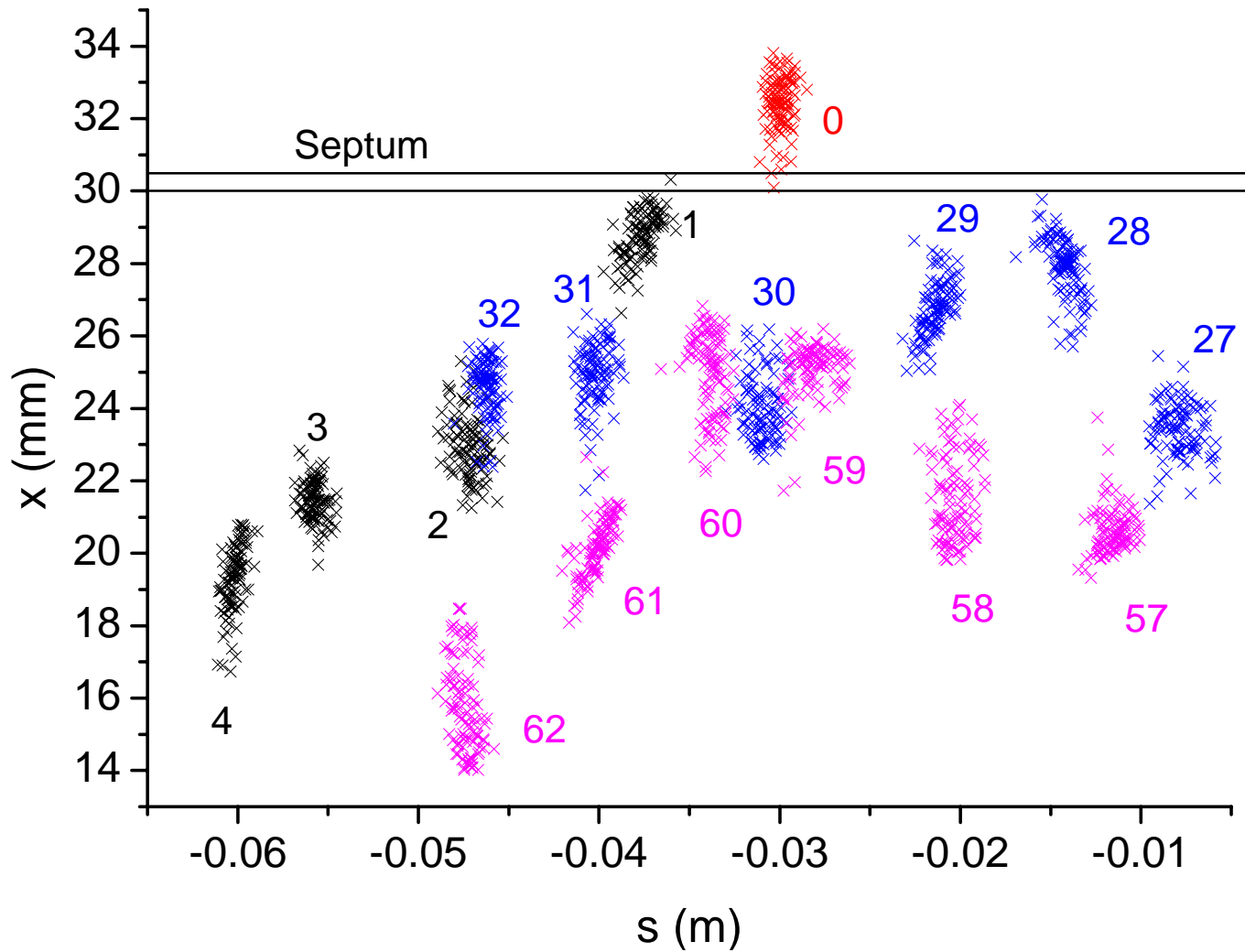
Ring circumference  $C = 100$  m, synchrotron damping  $\tau_s = 100 \mu\text{s}$  (333 turns)



Ring layout. Energy  $E_0 = 5$  GeV, circumference  $C \approx 125$  m, bend. field  $B = 6$  T, energy losses  $\Delta E \approx 20$  MeV / turn, synchrotron damping time  $\tau_s = 104 \mu\text{s}$ .  
 IS1, IS2, injection septums; RF, rf-sections; PE, positron extraction.



Dynamic aperture at injection azimuth. IB, injected beam; EO, equilibrium orbit; SB, septum blade. Momentum deviation  $\Delta p/p_0 = 3\%$ , dispersion at injection azimuth  $\eta = 1$  m.



Injection simulation. Numbers near bunch position indicate turn number (0 labels injected bunch)

## Simulation parameters&results:

Injected particles number 100;

Transversal beam emittance  $2000 \cdot 10^{-6} \text{ m} \cdot \text{rad}$  (normalized);

Energy distribution is Gaussian  $\Delta p/p_0 = 0.2 \% > (20-15)/5000$ ;

Septum thickness 0.5 mm;

Dispersion at injection azimuth  $\eta = 1 \text{ m}$ ;

Pulse deviation of injected beam from reference  $(p_{inj} - p_0)/p_0 = 3 \%$ .

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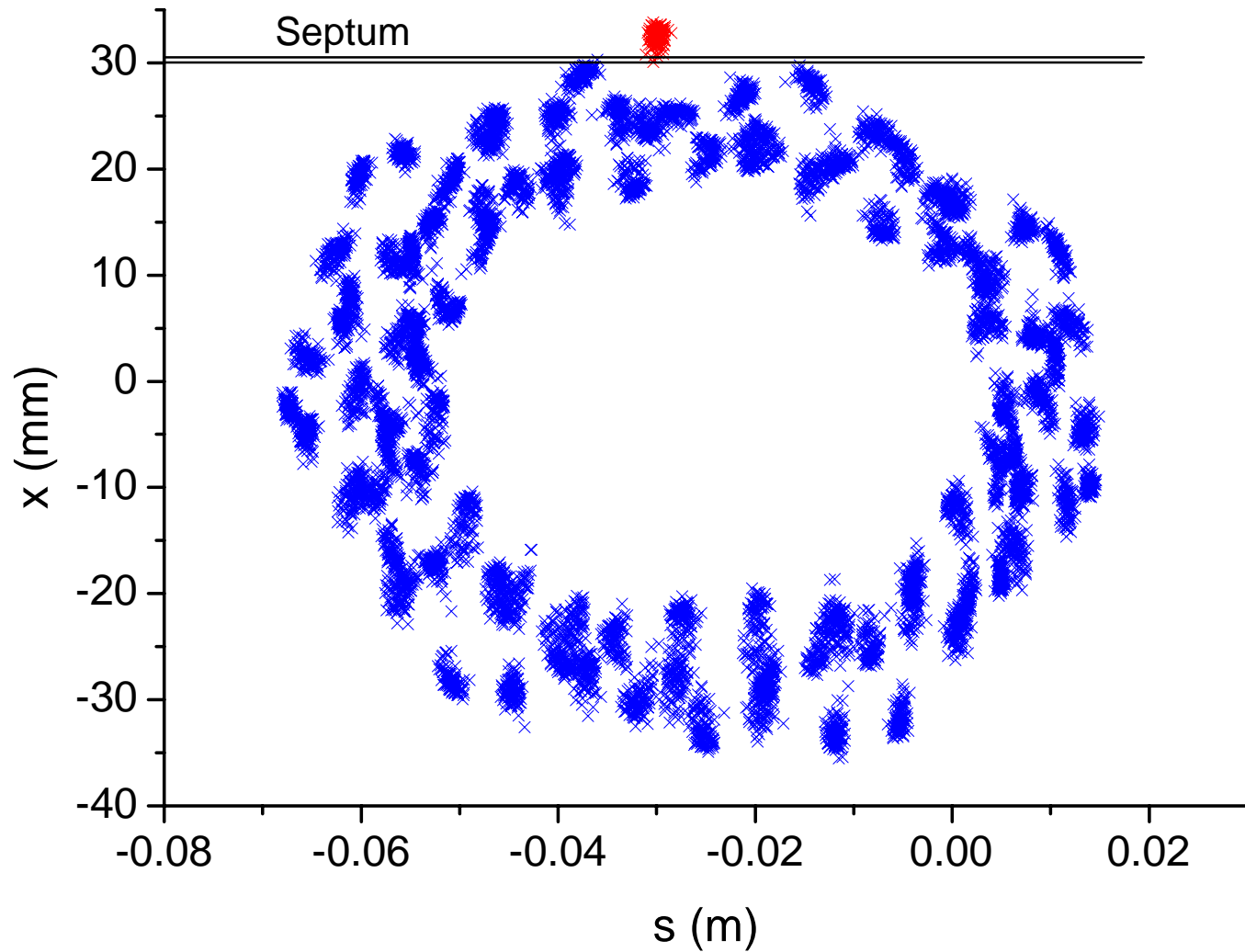
Two particles are out of the dynamic aperture and are lost during the injection;

One particle of the injected bunch is lost on septum;

Two particles are lost on septum blade after the first turn;

In the sequel particles are not lost.

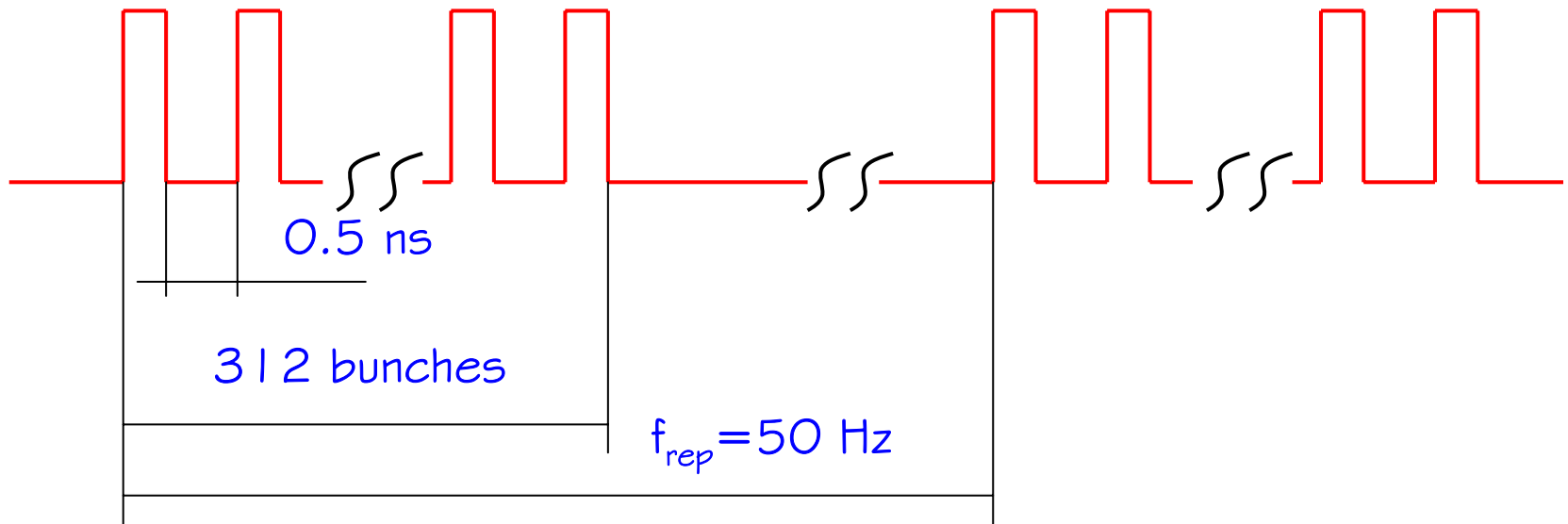
Thus, 95 particles are successfully injected,  
i.e. the injection efficiency is equal to 95 %.



*Positions of injected bunch during  
3 synchrotron cycles*

## Disadvantage #1

Crazy SR (RF) power

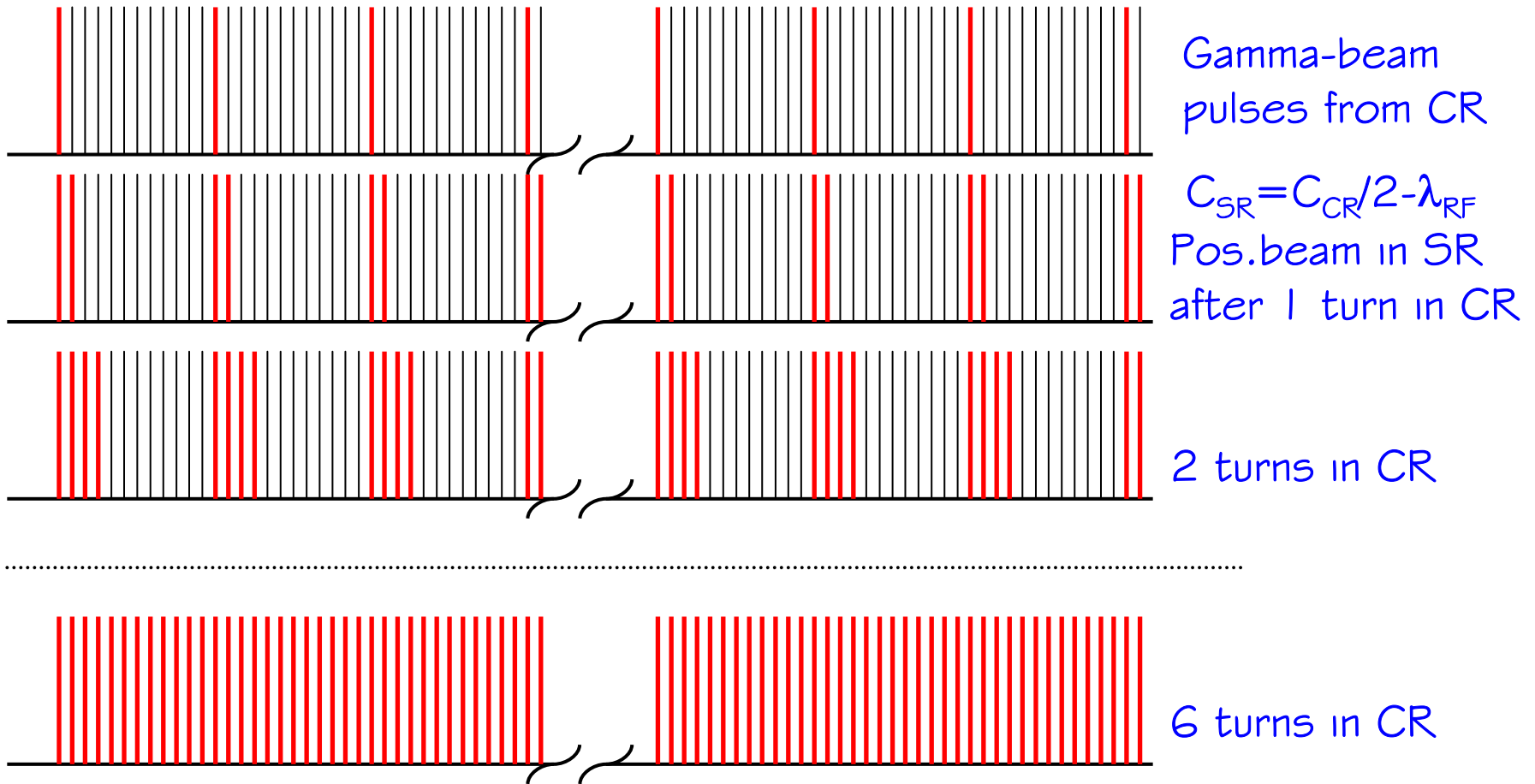


$$N_{\text{eb}} = 7 \cdot 10^9 \Rightarrow Q_{\text{b}} \approx 1.125 \text{ nC} \Rightarrow I_{\text{stor}} = 2.25 \text{ A},$$
$$\Delta E = 20 \text{ MeV}, P_{\text{SR}} = 45 \text{ MW} !!!$$

## Operation mode

CR: circumference  $C_{CR} \sim 300$  m, bunch spacing 6 ns ;

SR: circumference  $C_{SR} \sim 150$  m, bunch spacing 0.5 ns, bunch number  $N_b \sim 960$ ;



## Operation mode

TDT:  $C_{\text{TDT}} \sim 50$  m, bunch number  $N_b \sim 320$ , bunch spacing 0.5 ns.

CR: repetition rate  $f_{\text{rep}} = 2.5$  kHz ( $T_{\text{rep}} = 400$   $\mu\text{s} \Rightarrow 400$  turns = 100 turns (gamma generation) + 300 turns (beam damping);

SR: 200 turns (positron injection) + 600 turns (beam damping), after that quick positron beam extraction (3 turns in TDT) to TDT and just after that to pre-damping ring from TDT.

As a result: stored current in SR  $2.25$  A / 150 = 15 mA  $\Rightarrow P_{\text{SR}} = 300$  kW

At positron energy  $E_0 \sim 3.5$  GeV  $P_{\text{SR}} \sim 200$  kW, but larger beam emittance, larger required DA. Pulse deviation  $\sim 3.5$ -4 %

## Disadvantage #2

Large loss power.

$$I_{e^+} = 15 \mu\text{A}, k = 90\% \Rightarrow P_{\text{loss}} = 8 \text{ kW}$$

## Disadvantage #3

Large RF voltage  $V_{\text{rf}} = 50 \text{ MV}$

## Disadvantage #4

Superconductive linac with  
positron energy  $E_0 = 5 \text{ GeV}$

# Main parameters of stacking ring

Parameter	Value
Positron energy, GeV	5
Ring circumference, m	125.012
Bending field, T	6
RF frequency, GHz	2
RF voltage, MV	50
Harmonics number	834
Bunch spacing, ns	0.5
Beam energy losses, Mev/turn	19.8
Synchrotron damping time, $\mu$ s	104
Normalized emittance of injected beam, m*rad	$2000 \cdot 10^{-6}$
Dispersion at injection azimuth, m	1
Pulse deviation of injected beam, %	3
Injection efficiency, %	>90

# Summary

Stacking ring with the superconductive bendings for the continuous positron injection is proposed .

The injection efficiency into proposed stacking ring is greater than 90 %

The proposed ring can be used as the base for the further R&D